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PATENT APPLICATION
Q54388

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Atsushi SAKAI, et al.

Appln. No.: 09/576,957

Group Art Unit: 2822

Confirmation No.: 5486

Examiner: M. Trinh

Filed: May 24, 2000

For: SOLID ELECTROLYTIC CAPACITOR AND METHOD FOR PRODUCING THE SAME

AMENDMENT UNDER 37 C.F.R. § 1.111

Commissioner for Patents
Washington, D.C. 20231

Sir:

This Amendment is submitted in response to the Office Action dated February 28, 2002, in which the Examiner set a three month period for response.

IN THE CLAIMS:

Please enter the following amended claims:

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1. (Amended) A method for producing a solid electrolytic capacitor comprising a metal material having thereon a dielectric film having surface pores and a solid electrolyte formed on a desired position of the dielectric film, the metal material having valve action, wherein the method comprises the step of coating by press-contacting a masking material solution that infiltrates into the pores of the dielectric film and forms a masking layer on the infiltrated portion.

2. (Amended) A method for producing a solid electrolytic capacitor comprising a metal material having thereon a dielectric film having surface pores and a solid electrolyte formed on a desired position of the dielectric film, the metal material

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